

10. (Amended-Clean Text) The method according to claim 8, wherein the silicon-containing ceramic carrier is constructed with a carrier of silicide including a non-oxide ceramic such as silicon carbide or silicon nitride and an oxide ceramic such as sialon, mullite or cordierite.

11. (Amended-Clean Text) The method according to claim 8, wherein the silicon-containing ceramic carrier is any of a porous body, fiber shaped body and pellet shaped body.

12. (Amended-Clean Text) The method according to claim 8, wherein the silicon-containing ceramic carrier is formed by a honeycomb-like porous silicon carbide sintered body.

13. (Amended-Clean Text) The method according to claim 8, wherein the silicon-containing ceramic carrier has a  $\text{SiO}_2$  layer on its surface, and an amount of  $\text{SiO}_2$  occupied in the carrier is 0.001-20 wt%.

Please add new claims 14-18 as follows:

---14. A catalyst carrier according to claim 6, wherein the alumina thin film is an amount of 0.1-15 wt% per the carrier as an alumina amount.

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15. The method according to claim 9, wherein the silicon-containing ceramic carrier is constructed with a carrier of silicide including a non-oxide ceramic such as silicon carbide or silicon nitride and an oxide ceramic such as sialon, mullite or cordierite.

16. The method according to claim 9, wherein the silicon-containing ceramic carrier is any of a porous body, fiber shaped body and pellet shaped body.

17. The method according to claim 9, wherein the silicon-containing ceramic carrier is formed by a honeycomb-like porous silicon carbide sintered body.

18. The method according to claim 9, wherein the silicon-containing ceramic carrier has a SiO<sub>2</sub> layer on its surface, and an amount of SiO<sub>2</sub> occupied in the carrier is 0.001-20 wt%.---

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REMARKS

By the above amendment, claims 7, 10, 11, 12, and 13 have been amended and claims 14-18 have been added to delete multiple dependency.